

01-13-2005



Form PTO-1594 (Rev. 03/01) 1-11-05 RE
OMB No. 0651-0027 (exp. 5/31/2002)
Tab settings

102919225

U.S. DEPARTMENT OF COMMERCE
U.S. Patent and Trademark Office

To the Honorable Commissioner of Patents and Trademarks: Please record the attached original documents or copy thereof.

1. Name of conveying party(ies):

Molecular Imprints, Inc.

- Individual(s)
- General Partnership
- Corporation-State DE
- Other
- Association
- Limited Partnership

Additional name(s) of conveying party(ies) attached? Yes No

3. Nature of conveyance:

- Assignment
- Security Agreement
- Other
- Merger
- Change of Name

Execution Date: 9/28/04

2. Name and address of receiving party(ies)

Name: Venture Lending & Leasing IV, Inc.

Internal

Address:

Street Address: 2010 No. First St., Ste 310

City: San Jose State: CA Zip: 95131

- Individual(s) citizenship
- Association
- General Partnership
- Limited Partnership
- Corporation-State MD
- Other

If assignee is not domiciled in the United States, a domestic representative designation is attached: Yes No
(Designations must be a separate document from assignment)
Additional name(s) & address(es) attached? Yes No

4. Application number(s) or registration number(s):

A. Trademark Application No.(s) 76/453,571;
76/453,319; 76/453,866

B. Trademark Registration No.(s)

Additional number(s) attached Yes No

5. Name and address of party to whom correspondence concerning document should be mailed:

Name: Russell D. Pollock

Internal Address:

Street Address: Greene Radovsky Maloney & Share LLP

Four Embarcadero Center, Suite 4000

City: San Francisco State: CA Zip: 94111

6. Total number of applications and registrations involved:

13

7. Total fee (37 CFR 3.41).....\$ 340.00

- Enclosed
- Authorized to be charged to deposit account

8. Deposit account number:

DO NOT USE THIS SPACE

9. Signature.

Jeffrey T. Klugman

Name of Person Signing

Signature

12/28/04

Date

Total number of pages including cover sheet, attachments, and document:

18

Mail documents to be recorded with required cover sheet information to:
Commissioner of Patent & Trademarks, Box Assignments
Washington, D.C. 20231

01/12/2005 ECOOPER 00000089 76453571

01 FC:8521
02 FC:8522

40.00 OP
300.00 OP

TRADEMARK
REEL: 003103 FRAME: 0787

Recordation Form Cover Sheet
For Trademarks
Molecular Imprints, Inc.

76/453,858

76/470,850

76/470,855

76/491,646

76/491,647

76/550,047

76/547,676

76/545,673

76/365,083

76/365,081

45596/0829
12/28/04/MVR/277588.1

TRADEMARK
REEL: 003103 FRAME: 0788

INTELLECTUAL PROPERTY SECURITY AGREEMENT

This Intellectual Property Security Agreement (this "Agreement") is made as of September 28, 2004, by and between MOLECULAR IMPRINTS, INC., a Delaware corporation ("Grantor"), and VENTURE LENDING & LEASING IV, INC., a Maryland corporation ("Secured Party").

RECITALS

A. Pursuant to a Loan and Security Agreement of even date herewith (together with the Supplement to the Loan and Security Agreement, the "Loan Agreement") between Grantor, as borrower, and Secured Party, as lender, Secured Party has agreed to make certain advances of money and to extend certain financial accommodations to Grantor (the "Loans") in the amounts and manner set forth in the Loan Agreement. All capitalized terms used herein without definition shall have the meanings ascribed to them in the Loan Agreement.

B. Secured Party is willing to make the Loans to Grantor, but only upon the condition, among others, that Grantor shall grant to Secured Party a security interest in substantially all of Grantor's personal property whether presently existing or hereafter acquired. To that end, Grantor has executed in favor of Secured Party the Loan Agreement granting a security interest in all Collateral, and is executing this Agreement with respect to certain items of Intellectual Property, in particular.

NOW, THEREFORE, THE PARTIES HERETO AGREE AS FOLLOWS:

1. Grant of Security Interest. As collateral security for the prompt and complete payment and performance of all of Grantor's present or future Obligations, Grantor hereby grants a security interest to Secured Party, as security, in and to Grantor's entire right, title and interest in, to and under the following Intellectual Property, now owned or hereafter acquired by Grantor or in which Grantor now holds or hereafter acquires any interest (all of which shall collectively be called the "Collateral" for purposes of this Agreement):

(a) Any and all copyrights, whether registered or unregistered, held pursuant to the laws of the United States, any State thereof or of any other country; all registrations, applications and recordings in the United States Copyright Office or in any similar office or agency of the United States, and State thereof or any other country; all continuations, renewals, or extensions thereof; and any registrations to be issued under any pending applications; including without limitation those registered copyrights set forth on Exhibit A attached hereto (collectively, the "Copyrights");

(b) All letters patent of, or rights corresponding thereto in, the United States or any other country, all registrations and recordings thereof, and all applications for letters patent of, or rights corresponding thereto in, the United States or any other country, including, without limitation, registrations, recordings and applications in the United States Patent and Trademark Office or in any similar office or agency of the United States, any State thereof or any other country; all reissues, continuations, continuations-in-part or extensions thereof; all petty patents, divisionals, and patents of addition; and all patents to be issued under any such applications, including without limitation the patents and patent applications set forth on Exhibit B attached hereto (collectively, the "Patents");

(c) All trademarks, trade names, corporate names, business names, trade styles, service marks, logos, other source or business identifiers, prints and labels on which any of the foregoing have appeared or appear, designs and general intangibles of like nature, now existing or hereafter adopted or acquired, all registrations and recordings thereof, and any applications in connection therewith, including, without limitation, registrations, recordings and applications in the United States Patent and Trademark Office or in any similar office

or agency of the United States, any State thereof or any other country or any political subdivision thereof, and reissues, extensions or renewals thereof, and the entire goodwill of the business of Grantor connected with and symbolized by such trademarks, including without limitation those set forth on Exhibit C attached hereto (collectively, the "Trademarks");

(d) Any and all claims for damages by way of past, present and future infringement of any of the rights included above, with the right, but not the obligation, to sue for and collect such damages for said use or infringement of the intellectual property rights identified above;

(e) All licenses or other rights to use any of the Copyrights, Patents or Trademarks, and all license fees and royalties arising from such use to the extent permitted by such license or rights;

(f) All amendments, renewals and extensions of any of the Copyrights, Trademarks or Patents; and

(g) All proceeds and products of the foregoing, including without limitation all payments under insurance or any indemnity or warranty payable in respect of any of the foregoing.

Notwithstanding the foregoing the term "Collateral" shall not include: (a) "intent-to-use" trademarks at all times prior to the first use thereof, whether by the actual use thereof in commerce, the recording of a statement of use with the United States Patent and Trademark Office or otherwise, but only to the extent the granting of a security interest in such "intent to use" trademarks would forfeit Grantor's rights in such "intent to use" trademarks under applicable law or (b) any contract, instrument or chattel paper in which Grantor has any right, title or interest if and to the extent such contract, instrument or chattel paper includes a provision containing a restriction on assignment such that the creation of a security interest in the right, title or interest of Grantor therein would be prohibited and would, in and of itself, cause or result in a default thereunder enabling another person party to such contract, instrument or chattel paper to enforce any remedy with respect thereto; provided, however, that the foregoing exclusion shall not apply if (i) such prohibition has been waived or such other person has otherwise consented to the creation hereunder of a security interest in such contract, instrument or chattel paper, or (ii) such prohibition would be rendered ineffective pursuant to Sections 9-407(a) or 9-408(a) of Article 9 of the UCC, as applicable and as then in effect in any relevant jurisdiction, or any other applicable law (including the Bankruptcy Code) or principles of equity); provided further that immediately upon the ineffectiveness, lapse or termination of any such provision, the term "Collateral" shall include, and Grantor shall be deemed to have granted a security interest in, all its rights, title and interests in and to such contract, instrument or chattel paper as if such provision had never been in effect; and provided further that the foregoing exclusion shall in no way be construed so as to limit, impair or otherwise affect Secured Party's unconditional continuing security interest in and to all rights, title and interests of Grantor in or to any payment obligations or other rights to receive monies due or to become due under any such contract, instrument or chattel paper and in any such monies and other proceeds of such contract, instrument or chattel paper.

2. Covenants and Warranties. Grantor represents and warrants as of the date hereof and covenants and agrees as follows:

(a) Grantor is now the sole owner of the Collateral, except for Permitted Liens and non-exclusive licenses granted by Grantor in the ordinary course of business and, if approved by Grantor's Board of Directors, exclusive licenses of Intellectual Property to a licensee in or for a foreign territory or for a specific field of use;

(b) During the term of this Agreement, Grantor will not transfer or otherwise encumber any interest in the Collateral, except for Permitted Liens and non-exclusive licenses granted by Grantor in the ordinary

any way prevent the creation of a security interest in Grantor's rights and interests in any property included within the definition of the Collateral acquired under such contracts.

3. Further Assurances; Attorney in Fact.

(a) On a continuing basis, Grantor will make, execute, acknowledge and deliver, and file and record in the proper filing and recording places in the United States, all such instruments, including appropriate financing and continuation statements and collateral agreements and filings with the United States Patent and Trademark Office and the Register of Copyrights, and take all such action as may reasonably be deemed necessary or advisable, or as reasonably requested by Secured Party, to perfect Secured Party's security interest in all Copyrights, Patents and Trademarks and otherwise to carry out the intent and purposes of this Agreement, or for assuring and confirming to Secured Party the grant or perfection of a security interest in all Collateral.

(b) Grantor hereby irrevocably appoints Secured Party as Grantor's attorney-in-fact in respect of the Collateral, with full authority in the place and stead of Grantor and in the name of Grantor, from time to time in Secured Party's discretion, to take any action and to execute any instrument which Secured Party may deem necessary or advisable to accomplish the purposes of this Agreement, including (i) to modify, in its sole discretion, this Agreement without first obtaining Grantor's approval of or signature to such modification by amending Exhibits A, B and C, hereof, as appropriate, to include reference to any right, title or interest in any Copyrights, Patents or Trademarks acquired by Grantor after the execution hereof or to delete any reference to any right, title or interest in any Copyrights, Patents or Trademarks in which Grantor no longer has or claims any right, title or interest, (ii) to file, in its sole discretion, one or more financing or continuation statements and amendments thereto, relative to any of the Collateral without the signature of Grantor where permitted by law, and (iii) after the occurrence and during the continuance of an Event of Default, to transfer the Collateral into the name of Secured Party or a third party to the extent permitted under the California Uniform Commercial Code.

4. Events of Default. Events of Default. The occurrence of an Event of Default under the Loan Agreement shall constitute an Event of Default under this Agreement.

5. Amendments. This Agreement may be amended only by a written instrument signed by both parties hereto, except for amendments permitted under Section 3 hereof to be made by Secured Party alone.

6. Counterparts. This Agreement may be executed in two or more counterparts, each of which shall be deemed an original but all of which together shall constitute the same instrument.

[Remainder of this page intentionally left blank; signature page follows]

IN WITNESS WHEREOF, the parties hereto have executed this Agreement on the day and year first above written.

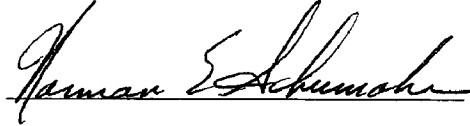
GRANTOR:

Address of Grantor:

1807-C West Braker Lane, #100
Austin, Texas 78758
Attn: Priscilla Johnsen

MOLECULAR IMPRINTS, INC.

By:



Name: Norman E. Schumaker

Its: President & CEO

SECURED PARTY:

Address of Secured Party:

2010 North First Street, Suite 310
San Jose, CA 95131
Attn: Chief Financial Officer

VENTURE LENDING & LEASING IV, INC.

By: _____

Name: _____

Its: _____

IN WITNESS WHEREOF, the parties hereto have executed this Agreement on the day and year first above written.

GRANTOR:

Address of Grantor:

MOLECULAR IMPRINTS, INC.

1807-C West Braker Lane, #100
Austin, Texas 78758
Attn: Priscilla Johnsen

By: _____

Name: _____


Its: _____

SECURED PARTY:

Address of Secured Party:

VENTURE LENDING & LEASING IV, INC.

2010 North First Street, Suite 310
San Jose, CA 95131
Attn: Chief Financial Officer

By:  _____

Name: Ronald W. Swenson

Its: Chief Executive Officer

EXHIBIT A

Copyrights

Description

Registration Number

Registration Date

None

EXHIBIT B

Patents

**MOLECULAR IMPRINTS, INC. IS THE SOLE OWNER OF THE RIGHTS IN THE
FOLLOWING U.S. PATENT DOCUMENTS**

Title	Filing Date	App. No.
1) Methods Of Manufacturing A Lithography Template	5/1/2002	10/136,188
2) Method For Dispensing Liquids (As Amended)	7/9/2002	10/191,749
3) Step And Repeat Imprint Lithography Process	7/11/2002	10/194,991
4) Step And Repeat Imprint Lithography Systems	7/11/2002	10/194,414
5) Formation Of Discontinuous Films During An Imprint Lithography Process	7/11/2002	10/194,411
6) Method And System For Imprint Lithography Using An Electric Field	7/11/2002	10/194,410
7) Alignment Systems For Imprint Lithography	8/1/2002	10/210,894
8) Scatterometry Alignment For Imprint Lithography	8/1/2002	10/210,785
9) Alignment Methods For Imprint Lithography	8/1/2002	10/210,780
10) Method For Fabricating Bulbous-Shaped Vias	8/23/2002	10/227,105
11) Functional Patterning Material For Imprint Lithography Processes	9/5/2002	10/235,314
12) A Method And A Mold To Arrange Features On A Substrate To Replicate Features Having Minimal Dimensional Variability	10/4/2002	10/264,960
13) A Method Of Forming A Layer On A Substrate To Facilitate Fabrication Of Metrology Standards	10/4/2002	10/264,926
14) Methods Of Inspecting A Lithography Template	11/13/2002	10/293,919
15) A Chucking System For Modulating Shapes Of Substrates	11/13/2002	10/293,224
16) Method Of Reducing Pattern Distortions During Imprint Lithography Processes	11/13/2002	10/293,223
17) A Method For Modulating Shapes Of Substrates	12/11/2002	10/316,963
18) Method And System For Determining Characteristics Of Substrates Employing Fluid Geometries	12/12/2002	10/318,365
19) Composition And Method To Form A Release Layer	2/27/2003	10/375,832
20) Method To Reduce Adhesion Between A Polymerizable Layer And A Substrate Employing A Fluorine-Containing Layer	2/27/2003	10/375,817
21) Positive Tone Bi-Layer Imprint Lithography Method	3/25/2003	10/396,615
22) A Method Of Forming Stepped Structures Employing Imprint Lithography	4/25/2003	10/423,642

Title	Filing Date	App. No.
23) Method, System And Holder For Transferring Templates During Imprint Lithography Processes	5/14/2003	10/438,224
24) Assembly And Method For Transferring Imprint Lithography Templates	5/14/2003	10/437,476
25) High-Resolution Overlay Alignment Systems For Imprint Lithography	5/27/2003	10/445,863
26) A Conforming Template For Patterning Liquids Disposed On Substrates	7/7/2003	10/614,716
27) Systems For Magnification And Distortion Correction For Imprint Lithography Processes	7/9/2003	10/616,294
28) Capillary Imprinting Technique	8/21/2003	10/645,306
29) Imprint Lithography Template Having Opaque Alignment Marks	9/25/2003	10/670,980
30) Formation Of Conductive Templates Employing Indium Tin Oxide	11/12/2003	10/706,537
31) Dispense Geometry To Achieve High-Speed Filling And Throughput	11/14/2003	10/714,088
32) Magnification Correction Employing Out-Of-Plane Distortion Of A Substrate	12/12/2003	10/735,110
33) Thermal Processing System For Imprint Lithography	1/15/2004	10/758,384
34) A Method To Improve The Flow Rate Of Imprinting Material	1/15/2004	10/757,778
35) Method For Concurrently Employing Differing Materials To Form A Layer On A Substrate	1/20/2004	10/760,821
36) Materials And Methods For Imprint Lithography	1/23/2004	10/763,885
37) Method And System To Measure Characteristics Of A Film Disposed On A Substrate	2/19/2004	10/782,187
38) Composition For An Etching Mask Comprising A Silicon-Containing Material	2/27/2004	10/789,319
39) Full-Wafer Or Large Area Imprinting With Multiple Separated Sub-Fields For High Throughput Lithography	2/27/2004	10/788,700
40) A Method Of Inspecting Substrates Employing Signal Superimposition	4/19/2004	10/827,119
41) Method Of Forming A Deep-Featured Template Employed In Imprint Lithography	4/19/2004	10/827,118
42) Compliant Hard Template For UV Imprinting	4/27/2004	10/833,240
43) Method Of Patterning A Conductive Layer On A Substrate	5/11/2004	10/843,194
44) A Method Of Forming A Recessed Structure Employing A Reverse Tone Process	5/21/2004	10/850,876

Title	Filing Date	App. No.
45) A Method Of Dispensing A Fluid On A Substrate	6/1/2004	10/858,566
46) A Compliant Device For Nano-Scale Manufacturing	6/1/2004	10/858,179
47) Method And System To Control Movement Of A Body For Nano-Scale Manufacturing	6/1/2004	10/858,100
48) System For Determining Characteristics Of Substrates Employing Fluid Geometries	6/8/2004	10/863,800
49) A Chucking System For Modulating Shapes Of Substrates	6/9/2004	10/864,591
50) System For Dispensing Liquids	6/15/2004	10/868,683
51) Imprint Alignment Method, System And Template	7/20/2004	10/895,214
52) Imprinting Of Displays	7/23/2004	10/897,734
53) Moat System For An Imprint Lithography Template	8/13/2004	10/917,761
54) A Method Of Planarizing A Semiconductor Substrate	8/13/2004	10/917,563
55) Method To Provide A Layer With Uniform Etch Characteristics	8/16/2004	10/919,224
56) Composition To Provide A Layer With Uniform Etch Characteristics	8/16/2004	10/919,062
57) Apparatus For Imprint Lithography Using An Electric Field	8/20/2004	10/923,629
58) System For Determining Characteristics Of Substrates Employing Fluid Geometries	8/20/2004	10/923,628

MOLECULAR IMPRINTS SHARES THE OWNERSHIP OF THE RIGHTS IN THE FOLLOWING U.S. PATENT DOCUMENTS WITH ONE OTHER ORGANIZATION

1) Low Viscosity High Resolution Patterning Material	6/24/2002	10/178,947
2) Method To Reduce Adhesion Between A Conformable Region And A Pattern Of A Mold	6/17/2003	10/463,396
3) Single Phase Fluid Imprint Lithography Method	10/2/2003	10/677,639
4) Applying Imprinting Material To Substrates Employing Electromagnetic Fields	10/16/2003	10/687,562
5) Low Surface Energy Templates	10/16/2003	10/687,519
6) Methods For Fabricating Patterned Features Utilizing Imprint Lithography	10/27/2003	10/694,284
7) Materials For Imprint Lithography	2/23/2004	10/784,911
8) An Apparatus For Creating A Turbulent Flow Of Fluid Between A Mold And A Substrate	7/23/2004	10/898,037
9) Method For Creating A Turbulent Flow Of Fluid Between A Mold And A Substrate	7/23/2004	10/898,034

**MOLECULAR IMPRINTS, INC. IS THE SOLE OWNER OF THE RIGHTS IN THE
FOLLOWING INTERNATIONAL AND FOREIGN PATENT DOCUMENTS**

1)	A Chucking System and Method for Modulating Shapes of Substrates	PCT	Nov 12, 2003	PCT/US03/36012
2)	A Chucking System and Method for Modulating Shapes of Substrates	MY	Nov 12, 2003	PI 20034332
3)	A Chucking System and Method for Modulating Shapes of Substrates	TW	Nov 12, 2003	92131719
4)	A Chucking System and Method for Modulating Shapes of Substrates	DE	May 17, 2004	203 20 446.8
5)	A Method and a Mold to Arrange Features on a Substrate to Replicate Features Having Minimal Dimensional Variability	PCT	Sep 18, 2003	PCT/US03/29061
6)	A Method and a Mold to Arrange Features on a Substrate to Replicate Features Having Minimal Dimensional Variability	MY	Sep 25, 2003	PI 20033654
7)	A Method and a Mold to Arrange Features on a Substrate to Replicate Features Having Minimal Dimensional Variability	TW	Sep 26, 2003	92126696
8)	A Method of Forming Stepped Structures Employing Imprint Lithography	PCT	Apr 21, 2004	PCT/US04/12313
9)	A Method of Forming Stepped Structures Employing Imprint Lithography	MY	Apr 23, 2004	PI 20041496
10)	A Method of Forming Stepped Structures Employing Imprint Lithography	TW	Apr 23, 2004	93111426
11)	Capillary Imprinting Technique	PCT	Aug 13, 2004	PCT/US04/26337
12)	Capillary Imprinting Technique	PCT	Aug 13, 2004	PCT/US04/26337
13)	Capillary Imprinting Technique	MY	Aug 17, 2004	
14)	Capillary Imprinting Technique	TW	Aug 20, 2004	93125173
15)	Formation of Discontinuous Films During an Imprint Lithography Process	PCT	Jul 10, 2003	PCT/US03/21556
16)	Formation of Discontinuous Films During an Imprint Lithography Process	MY	Jul 7, 2003	PI 20032546
17)	Formation of Discontinuous Films During an Imprint Lithography Process	TW	Jul 10, 2003	92118881
18)	Magnification Correction Employing Out-Of-Plane Distortion of a Substrate	PCT	Dec 12, 2003	PCT/US03/39448
19)	Magnification Correction Employing Out-Of-Plane Distortion of a Substrate	MY	Dec 12, 2003	PI 20034775
20)	Magnification Correction Employing Out-Of-Plane Distortion of a Substrate	TW	Dec 12, 2003	92135221
21)	Method And System For Determining Characteristics Of Substrates Employing Fluid Geometries	PCT	Dec 12, 2003	PCT/US03/39449
22)	Method and System for Imprint Lithography Using an Electric Field	MY	Jul 7, 2003	PI 20032545
23)	Method and System for Imprint Lithography Using an Electric Field	TW	Jul 10, 2003	92118873

24) Method, System, Holder and Assembly for Transferring Templates during Imprint Lithography Processes	PCT	May 11, 2004	PCT/US04/14720
25) Positive Tone Bi-Layer Imprint Lithography Method and Compositions Therefor	PCT	Mar 24, 2004	PCT/US04/08920
26) Positive Tone Bi-Layer Imprint Lithography Method and Compositions Therefor	MY	Mar 25, 2004	PI 20041060
27) Positive Tone Bi-Layer Imprint Lithography Method and Compositions Therefor	TW	Mar 24, 2004	93107963
28) Scatterometry Alignment for Imprint Lithography	PCT	Jul 31, 2003	PCT/US03/23948
29) Scatterometry Alignment for Imprint Lithography	MY	Jul 30, 2003	PI 20032888
30) Scatterometry Alignment for Imprint Lithography	TW	Jul 31, 2003	92120993
31) Step and Repeat Imprint Lithography Process	MY	Jul 7, 2003	PI 20032541
32) Step and Repeat Imprint Lithography Process	TW	Jul 10, 2003	92118862
33) Step and Repeat Imprint Lithography Systems	MY	Jul 7, 2003	PI-20032540
34) Step and Repeat Imprint Lithography Systems	TW	Jul 10, 2003	92118883
35) System and Method for Dispensing Liquids	PCT	Jun 19, 2003	PCT/US03/19258
36) System and Method for Dispensing Liquids	MY	Jun 27, 2003	PI-20032433
37) System and Method for Dispensing Liquids	TW	Jun 30, 2003	92117835
38) Systems for Magnification and Distortion Correction for Imprint Lithography Processes	PCT	Jul 9, 2004	PCT/US04/22454
39) Systems for Magnification and Distortion Correction for Imprint Lithography Processes	MY	Jul 9, 2004	PI 20042743
40) Systems for Magnification and Distortion Correction for Imprint Lithography Processes	TW	Jul 8, 2004	93120450

MOLECULAR IMPRINTS SHARES THE OWNERSHIP OF THE RIGHTS IN THE FOLLOWING INTERNATIONAL AND FOREIGN DOCUMENTS WITH ONE OTHER ORGANIZATION

1) Method to Reduce Adhesion Between a Conformable Region and a Pattern of a Mold	PCT	6/10/2004	PCT/US2004/01885 7
2) Method to Reduce Adhesion Between a Conformable Region and a Pattern of a Mold	MY	6/15/2004	PI 20042293
3) Method to Reduce Adhesion Between a Conformable Region and a Pattern of a Mold	TW	6/16/2004	93117326

EXHIBIT C

Trademarks

U.S. Trademarks

Description	Registration/ Application Number	Application Date
S-FIL	76/453,571	9/27/2002
SFIL	76/453,319	9/26/2002
S-FIL	76/453,866	9/30/2002
SFIL	76/453,858	9/30/2002
IMPRIIO	76/470,850	11/29/2002
IMPRIIO	76/470,855	11/29/2002
S-FIL/MONOMAT	76/491,646	2/19/2003
MONOMAT	76/491,647	2/19/2003
Eightbar (graphic)	76/550,047	9/22/2003
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	76/547,676	9/22/2003
MOLECULAR IMPRINTS	76/545,673	9/22/2003
STEP AND FLASH	76/365,083	1/30/2002
STEP AND FLASH	76/365,081	1/30/2002

Foreign Trademarks

Description		Registration/ Application Number	Application Date
MONOMAT	EU	003316114	8/18/2003
MONOMAT	JP	2003-070305	8/19/2003
MONOMAT	CN	3681076	8/19/2003

MONOMAT	KR	40-2003-36898	8/19/2003
MONOMAT	TW	92050098	8/19/2003
MONOMAT	MY	2003/10561	8/19/2003
MONOMAT	SG	T03/12722G	8/19/2003
IMPRIO	CN	3572873	5/29/2003
IMPRIO	EU	003183332	5/27/2003
IMPRIO	JP	2003-044000	5/29/2003
IMPRIO	KR	41-2003-11068	5/27/2003
IMPRIO	MY	2003/06352	5/28/2003
IMPRIO	SG	T03/08003D	5/28/2003
IMPRIO	TW	92034271	5/28/2003
IMPRIO	CN	3572872	5/29/2003
IMPRIO	MY	2003/06351	5/28/2003
IMPRIO	SG	T03/08002F	5/28/2003
IMPRIO	JP	2003-044001	5/29/2003
IMPRIO	KR	40-2003-23757	5/27/2003
IMPRIO	TW	92034269	5/28/2003
EIGHTBAR	CN	3971212	3/22/2004
EIGHTBAR	EU	003722667	3/22/2004

EIGHTBAR	JP	2004-026533	3/22/2004
EIGHTBAR	KR	40-2004-12755	3/22/2004
EIGHTBAR	MY	2004/03539	3/22/2004
EIGHTBAR	SG	T04/04392B	3/22/2004
EIGHTBAR	TW	93012315	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	CN	3971211	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	EU	003721446	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	JP	2004-26534	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	KR	40-2004-12756	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	MY	2004/03537	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	SG	T04/04391D	3/22/2004
BUILDING THE TOOLS THAT BUILD THE NANO-WORLD	TW	93012305	3/22/2004
MOLECULAR IMPRINTS	TW	93012313	3/22/2004
MOLECULAR IMPRINTS	CN	3971213	3/22/2004
MOLECULAR IMPRINTS	EU	003721602	3/22/2004
MOLECULAR IMPRINTS	JP	2004-26535	3/22/2004
MOLECULAR IMPRINTS	KR	40-2004-12757	3/22/2004

MOLECULAR IMPRINTS

MY

2004/03538

3/22/2004

MOLECULAR IMPRINTS

SG

T04/04390F

3/22/2004

45596/0829
JTK/271197.3

15

3-1

RECORDED: 01/11/2005

TRADEMARK
REEL: 003103 FRAME: 0803